	Application No.	Applicant(s)
Notice of Allowability	10/693,244	TSUJIMURA ET AL.
	Examiner	Art Unit
	David Turocy	1762
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>7/30/2007</u> .		
2. The allowed claim(s) is/are 1,3-8,10,12-14,17,18 and 26-31.		
 3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
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Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. ☐ Notice of Informal F	Patent Application
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	(PTO-413),
3. Information Disclosure Statements (PTO/SB/08),	Paper No./Mail Da 7. ☐ Examiner's Amendi	
Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit	•	ent of Reasons for Allowance
of Biological Material	9. Other	
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Application/Control Number: 10/693,244 Page 2

Art Unit: 1762

DETAILED ACTION

Response to Arguments

1. Applicant's arguments, filed 7/30/2007, with respect to the 35 USC 112 1st paragraph rejection has been fully considered and are persuasive. The examiner notes the full disclosure of the specification discloses supplying gases in a ratio that will only form microcrystalline film and therefore the examiner agrees that the specification suggests to one of ordinary skill in the art to deposit a microcrystalline thin film without converting amorphous silicon to microcrystals as required by the claim. As noted below, the prior art fails to suggest or make obvious the flow rate ratio as required to deposit a microcrystalline thin film without converting amorphous silicon to microcrystals.

Allowable Subject Matter

- 2. Claims 1, 3-8, 10, 12-14, 17-18, and 26-31 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:
- 4. Claims are allowed for the same reasons as set forth in the office action dated 12/6/2006.

Claim 1 and dependants: None of the prior art cited or reviewed by the examiner alone or in combination reasonably suggests forming the microcrystalline layer without converting amorphous silicon to microcrystals with the claim as written as discussed in the Remarks dated 7/30/2007 and section 1 above. Specifically, none of the prior art cited or reviewed by the examiner alone or in combination reasonably suggests

Application/Control Number: 10/693,244

Art Unit: 1762

7.0011101 Number: 10/095,2-

supplying in a first process H₂ and SiH₄ in a ratio to deposit a microcrystalline layer without converting amorphous silicon to microcrystals.

Claim 26, 28, 29, and 31 and dependants: None of the prior art cited or reviewed by the examiner alone or in combination reasonably suggests supplying in a first process H₂ and SiH₄ in a ratio to prevent amorphous deposition and then stopping the SiH₄ to deposit microcrystalline silicon.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Turocy whose telephone number is (571) 272-2940. The examiner can normally be reached on Monday-Friday 8:30-6:00, No 2nd Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Art Unit: 1762

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/David Turocy/ Patent Examiner AU 1762

TIMOTHY MEEKS
SUPERVISORY PATENT EXAMINER

Page 4